# **TCT measurements on Magnetic-Cz and Fz material**

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Motivation:

Is Okmetic-Cz material inverted after proton irradiation?

- •how to determine space charge sign in irradiated silicon
- •how to interpret the measurements

Helsinki samples from Jakko Haerkoenen

•Fz - 1.2 kΩcm (*V<sub>FD</sub>*=260 V), 300 μm

•Okmetic(magnetic) Cz - 1.1 k $\Omega$ cm ( $V_{FD}$ =300 V), 300  $\mu$ m

Irradiation:

•fluence: 1x10<sup>14</sup> p/cm<sup>2</sup> (Fz,Cz)

•fluence: 5x10<sup>14</sup> p/cm<sup>2</sup> (Fz,Cz)

History: samples were annealed 2 weeks at RT

Measurements: TCT using the red laser

#### How to interpret Q(U) curves - diodes irradiated to "low" fluence?



#### **TCT current pulses - diodes irradiated to "low" fluence?**



t[ns]

0.1

Fz-1e14

t[ns]

0.15

0.05

.1⊨

Fz—1e14

# Cz – Irradiated to 5e14



Charge plot for electrons/holes show that  $N_{eff}$  is not constant Large hole signal (charge) already at low voltages – injection in electric field region



Both electron and hole seems to be injected in high field region, but... what we measure/see is damped by trapping of the drifting charge

$$I_{e,h}(t) = N_0 \exp(\frac{-t}{\tau_{eff_{e,h}}}) \frac{1}{D} v_{e,h}(t)$$

To derive the electric field profile/space charge sign you must take trapping into account!

#### **HOLE SIGNALS – Cz detector**

TCT Measurement @ T=-10 C



<u>After full depletion</u> the slope of I(t) does not change sign  $N_{eff}$  is of the same sign – not inverted !

larger U -> larger slope -> change in Neff rough explanation:

trapping of the free carriers (leakage current) is responsible for change in  $N_{eff}$ 

$$I_{e} = -e_{0} \cdot n \cdot v_{e}$$

$$I_{h} = e_{0} \cdot p \cdot v_{h}$$

$$\rightarrow n, p \text{ depend on } U, \text{ hence occupation probability and } N_{eff} \text{ as well}$$

#### **ELECTRON SIGNALS – Cz detector**



Same conclusions can be drawn as from the hole signal!



For FZ material it is impossible to determine the space charge sign!





# **Determination of trapping times**

Using CCM/ECC the trapping times were derived. For both materials they are compatible with previous measurements! no dependence of trapping times on material type



# Conclusions

2 Fz and 2 Magnetic-Cz diodes irradiated to 10<sup>14</sup> cm<sup>-2</sup> and 5x10<sup>14</sup> cm<sup>-2</sup> were studied!

Cz material is found not-inverted at voltages above  $V_{FD}$  for both fluences (below full depletion voltages sign of the space charge is not well defined), while Fz material is inverted at larger fluence !

In order to determine sign of the space charge from TCT signals one must take trapping into account!

In many cases space charge sign can be deduced also from Q(V) plot!

# **Electric field profile in the detector (diode)**

induced current pulse shape (measured) extract E(x) (E(x(t)), x(t)) weighting field (pad detector-1/D) mobility parameterization (literature) effective trapping times of *e*,*h* determine  $N_{eff}(x)$  $(I_{e,h}(t)) = N_0 \exp(\frac{-\iota}{\tau_{eff_{e,h}}}) \frac{1}{D} v_{e,h}(t)$ input-meas. parameters  $(x_{e,h}(t)) = \int_{t_0}^t I_{e,h}(t') \frac{D}{N_0} \exp(\frac{t'}{\tau_{eff_{e,h}}}) dt' \implies D = x_{e,h}(t_t)$ unknown parameters  $v_{e,h}(t) = \mu_{e,h}(E(t)) E(t) = I_{e,h}(t) \frac{D}{N_0} \exp(\frac{t}{\tau_{eff}})$ 

More reliable determination from holes signals (longer signal, less influence of laser width)!



Figure 5.15 : a.) Induced current after hole injection for sample W317 irradiated with neutrons to  $\Phi_{\rm eq} = 7.5 \cdot 10^{13} \text{ cm}^{-1} (V_{FD} = 103 \text{ V})$ . Measurements were performed at  $T = 10^{\circ}$ C. b.) The induced currents from a.) are scaled with  $\sqrt{10 \text{ V/U}}$ . The scaling factor is given in brackets.

$$t_c = \frac{w}{v_{dr_h}} = \frac{w^2}{\mu_{0_h} U} \propto \frac{1}{\mu_{0_h}} , \quad w^2 \propto U.$$

## Standard material irradiated with <u>neutrons:</u>

## Oxygenated material irradiated with <u>neutrons:</u>



## Standard material irradiated with <u>protons:</u>

### Oxygenated material irradiated with <u>protons:</u>





## Oxygenated material irradiated with protons to high fluence

In oxygenated material electric field is more uniform (lower  $V_{FD}$ ) after irradiation with charged hadrons compared to standard material!



G. Kramberger, Jožef Stefan Institute, Ljubljana, Slovenia Signal formation in irradiated silicon detectors, Hamburg, March 2001

# Standard material irradiated with <u>protons</u> to high fluence

Less overdepletion is needed for the same CCE, but at high voltages there should not be any difference!

